

Notice of References Cited

Application/Control No.

09/885,744

Applicant(s)/Patent Under
Reexamination
NIIMI ET AL.

Examiner

Khiem D Nguyen

Art Unit

2823

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U.S. PATENT DOCUMENTS

*	Document Number Country Code-Number-Kind Code	Date MM-YYYY	Name	Classification
A	US-6,136,654	10-2000	Kraft et al.	438/287
B	US-6,391,724	05-2002	Dae-Gyu Park	438/279
C	US-			
D	US-			
E	US-			
F	US-			
G	US-			
H	US-			
I	US-			
J	US-			
K	US-			
L	US-			
M	US-			

FOREIGN PATENT DOCUMENTS

*	Document Number Country Code-Number-Kind Code	Date MM-YYYY	Country	Name	Classification
N					
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R					
S					
T					

NON-PATENT DOCUMENTS

*	Include as applicable: Author, Title Date, Publisher, Edition or Volume, Pertinent Pages		
U	Park et al. Pub. US 2001/027004	Semiconductor Device Having Capacitor And Method Of Manufacturing The Same, Aug. 16, 2001	
V	Weimer et al. Pub. US 2001/0014522	Forming A Conductive Structure In A Semiconductor Device, Aug. 16, 2001.	
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*A copy of this reference is not being furnished with this Office action. (See MPEP § 707.05(a).)
Dates in MM-YYYY format are publication dates. Classifications may be US or foreign.